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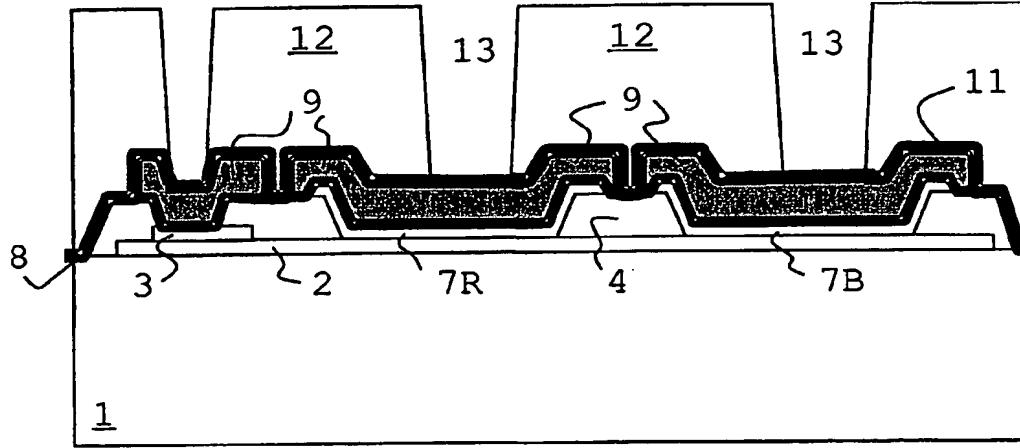
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(54) Title: METHOD FOR MANUFACTURING A LIGHT-EMITTING DISPLAY



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(57) **Abstract:** The invention relates to a method for manufacturing a light emitting display on a substrate comprising the steps of depositing a first electrode layer on or over the substrate, forming a plurality of light emitting layer segments on or over at least a part of the first electrode layer, applying at least one protective layer on or over at least one of the light emitting layer segments and depositing a second electrode layer. By providing a protective layer over the light emitting layer segments more freedom with regard to processing conditions is obtained in depositing and/or patterning of subsequent layers, since the susceptible light emitting layer segments are protected by the protective layers.